

Supplementary Data

The Impact of Co Doping and Annealing Temperature on the Electrochemical Performance and Structural Characteristics of SnO₂ Nanoparticulate Photoanodes

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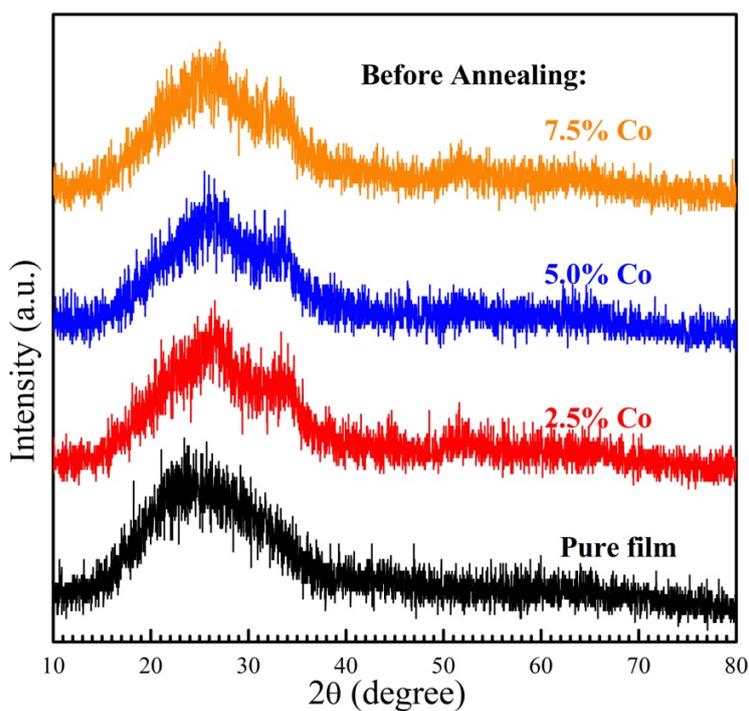


Figure S1. Shows XRD patterns of the as-deposited films (before annealing).

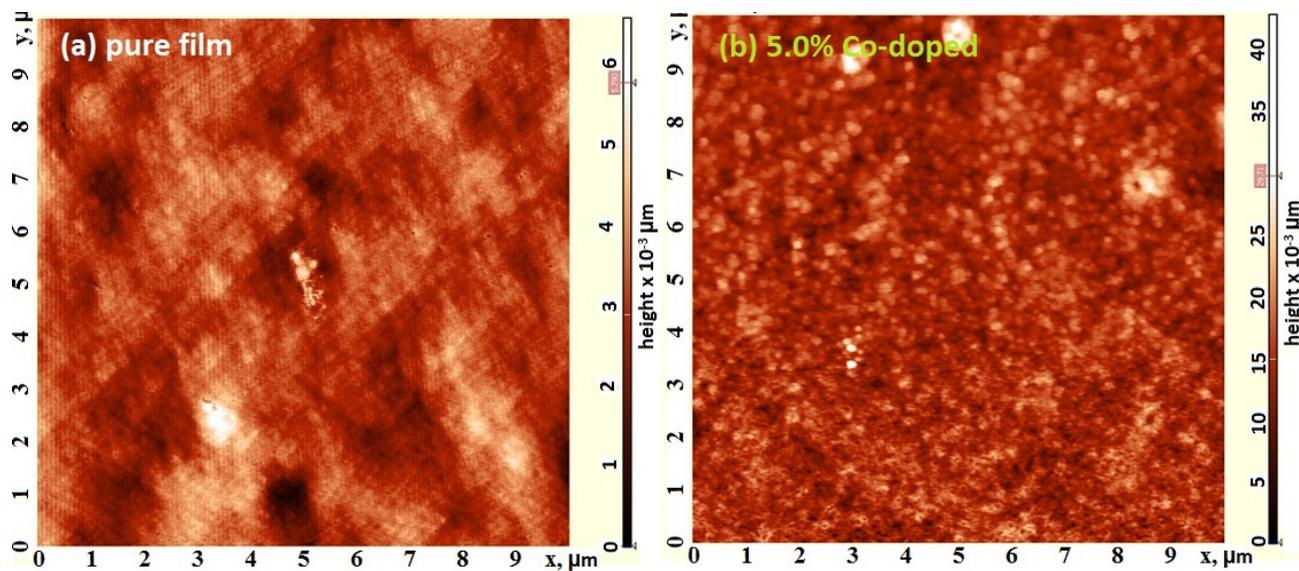


Figure S2. 2D AFM images for (a) pure and (b) 5.0% Co-doped films before annealing.